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1713Invention: **COMPOSITION FOR ANTIREFLECTIVE COATING AND METHOD FOR FORMING SAME****SEP 16 2005**I hereby certify that this **English Language abstract of JP 08-0305032 - 2 Pages**
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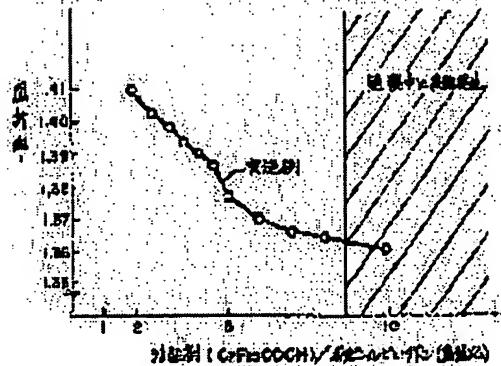
(22)Date of filing : 01.05.1995 (72)Inventor : IWATA YUTAKA
YOSHIDA TAKEO

(54) COMPOSITION FOR ANTIREFLECTION COATING

(57)Abstract:

PURPOSE: To obtain a compsn. for forming a high quality anti-interference film on a photoresist film by incorporating perfluoro alkylcarboxylic acid, org. amine, polyvinylpyrrolidone and water.

CONSTITUTION: This compsn. contains perfluoroalkylcarboxylic acid, org. amine, polyvinylpyrrolidone and water. The perfluoroalkylcarboxylic acid is a compd. represented by the formula $C_nF_{2n+1} COOH$ [where (n) is 5-10] and $C_7F_{15}COOH$ is preferably used. The perfluoroalkylcarboxylic acid is used as an activator and dissolves under coexistence of a basic substance. The basic substance used here is the org. amine and alkanolamine, especially monoethanolamine is preferably used. By the combination of the components, a lower refractive index is ensured and a slightly soluble layer is not formed on a resist.



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